

Lecture #5

ANNOUNCEMENT

- Discussion Section 102 (Th 10-11AM) moved to **105 Latimer**

OUTLINE

- Mobility dependence on temperature
- Diffusion current
- Relationship between band diagrams & V , ϵ
- Non-uniformly doped semiconductor
- Einstein relationship
- Quasi-neutrality approximation

Read: Chapter 3.2

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Mechanisms of Carrier Scattering

Dominant scattering mechanisms:

1. Phonon scattering (lattice scattering)
2. Impurity (dopant) ion scattering

Phonon scattering mobility decreases when T increases:

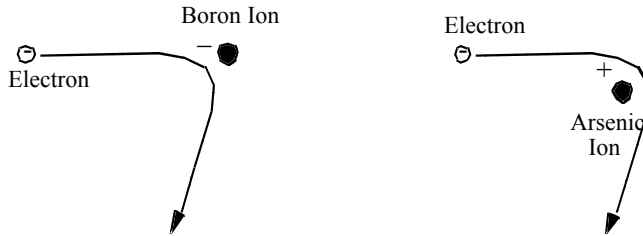
$$\mu_{\text{phonon}} \propto \tau_{\text{phonon}} \propto \frac{1}{\text{phonon density} \times \text{carrier thermal velocity}} \propto \frac{1}{T \times T^{1/2}} \propto T^{-3/2}$$

$\mu = q\tau/m$ $v_{th} \propto \sqrt{T}$

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Impurity Ion Scattering



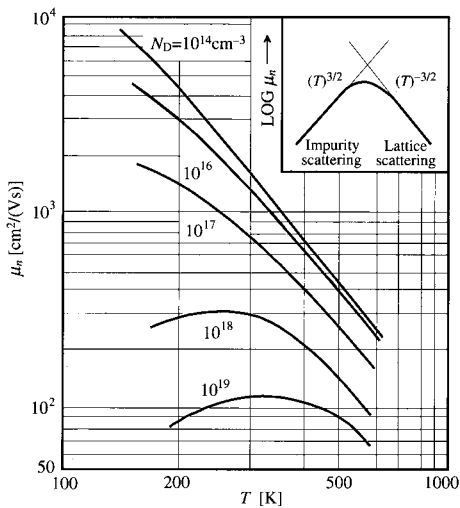
There is less change in the electron's direction of travel if the electron zips by the ion at a higher speed.

$$\mu_{impurity} \propto \frac{v_{th}^3}{N_A + N_D} \propto \frac{T^{3/2}}{N_A + N_D}$$

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Temperature Effect on Mobility



$$\frac{1}{\tau} = \frac{1}{\tau_{phonon}} + \frac{1}{\tau_{impurity}}$$

$$\frac{1}{\mu} = \frac{1}{\mu_{phonon}} + \frac{1}{\mu_{impurity}}$$

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Example: Temperature Dependence of ρ

Consider a Si sample doped with 10^{17}cm^{-3} As.
How will its resistivity change when the temperature is increased from $T=300\text{K}$ to $T=400\text{K}$?

Solution:

The temperature dependent factor in σ (and therefore ρ) is μ_n . From the mobility vs. temperature curve for 10^{17}cm^{-3} , we find that μ_n decreases from 770 at 300K to 400 at 400K. As a result, ρ **increases** by

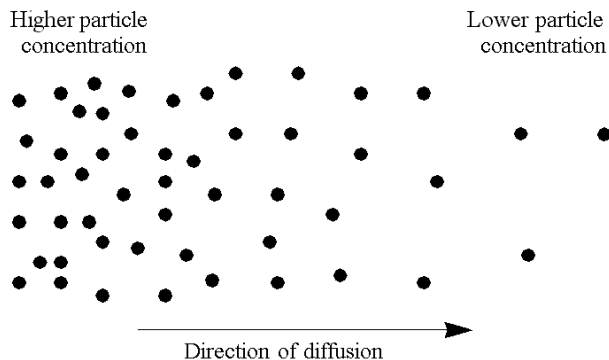
$$\frac{770}{400} = 1.93$$

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Diffusion

Particles diffuse from regions of higher concentration to regions of lower concentration region, due to random thermal motion.



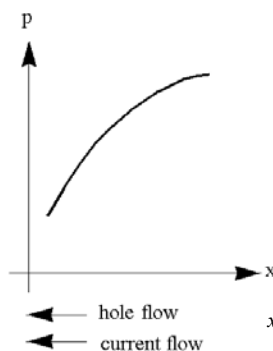
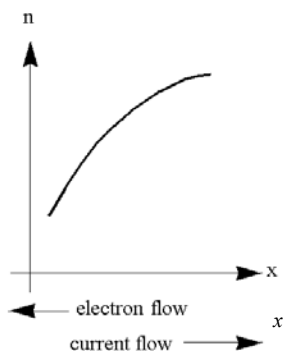
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Diffusion Current

$$J_{N,diff} = qD_N \frac{dn}{dx}$$

$$J_{P,diff} = -qD_P \frac{dp}{dx}$$



D is the **diffusion constant**, or **diffusivity**.

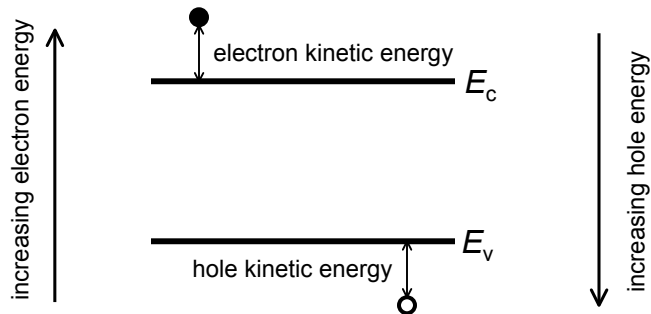
Total Current

$$J = J_N + J_P$$

$$J_N = J_{N,drift} + J_{N,diff} = qn\mu_n\mathcal{E} + qD_N \frac{dn}{dx}$$

$$J_P = J_{P,drift} + J_{P,diff} = qp\mu_p\mathcal{E} - qD_P \frac{dp}{dx}$$

Band Diagram: Potential vs. Kinetic Energy



E_c represents the electron potential energy:

$$\text{P.E.} = E_c - E_{\text{reference}}$$

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Electrostatic Potential V



- Potential energy of a $-q$ charged particle is related to the electrostatic potential $V(x)$:

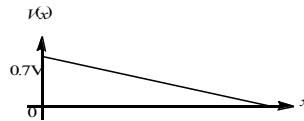
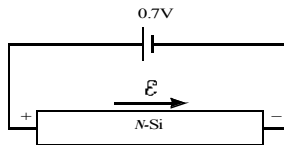
$$\text{P.E.} = -qV$$

$$V = \frac{1}{q}(E_{\text{reference}} - E_c)$$

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Electric Field \mathcal{E}



$$\mathcal{E} = -\frac{dV}{dx} = \frac{1}{q} \frac{dE_c}{dx}$$

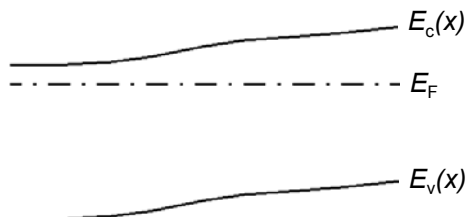
- Variation of E_c with position is called “**band bending.**”

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Non-Uniformly-Doped Semiconductor

- The position of E_F relative to the band edges is determined by the carrier concentrations, which is determined by the dopant concentrations.
- **In equilibrium, E_F is constant**; therefore, the band energies vary with position:



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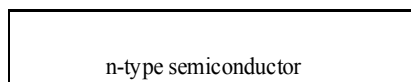
- In equilibrium, there is no net flow of electrons or holes

$$J_N = 0 \quad \text{and} \quad J_P = 0$$

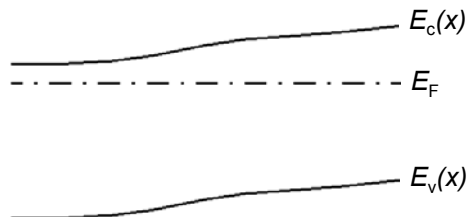
- ➔ The drift and diffusion current components must balance each other exactly. (A built-in electric field exists, such that the drift current exactly cancels out the diffusion current due to the concentration gradient.)

$$J_N = qn\mu_n\mathcal{E} + qD_N\frac{dn}{dx} = 0$$

Consider a piece of a non-uniformly doped semiconductor:



Decreasing donor concentration



$$n = N_c e^{-(E_c - E_F)/kT}$$

$$\frac{dn}{dx} = -\frac{N_c}{kT} e^{-(E_c - E_F)/kT} \frac{dE_c}{dx}$$

$$= -\frac{n}{kT} \frac{dE_c}{dx}$$

$$= -\frac{n}{kT} q\mathcal{E}$$

Einstein Relationship between D and μ

Under equilibrium conditions, $J_N = 0$ and $J_P = 0$

$$J_N = qn\mu_n\mathcal{E} + qD_N\frac{dn}{dx} = 0$$

$$0 = qn\mu_n\mathcal{E} - qn\frac{qD_N}{kT}\mathcal{E} \quad \rightarrow \quad D_N = \frac{kT}{q}\mu_n$$

Similarly, $D_P = \frac{kT}{q}\mu_p$

Note: The Einstein relationship is valid for a non-degenerate semiconductor, even under non-equilibrium conditions

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Example: Diffusion Constant

What is the hole diffusion constant in a sample of silicon with $\mu_p = 410 \text{ cm}^2 / \text{V s}$?

Solution:

$$D_p = \left(\frac{kT}{q} \right) \mu_p = (26 \text{ mV}) \cdot 410 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1} = 11 \text{ cm}^2/\text{s}$$

Remember: $kT/q = 26 \text{ mV}$ at room temperature.

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Potential Difference due to $n(x)$, $p(x)$

- The ratio of carrier densities (n , p) at two points depends exponentially on the potential difference between these points:

$$E_F - E_{i1} = kT \ln\left(\frac{n_1}{n_i}\right) \Rightarrow E_{i1} = E_F - kT \ln\left(\frac{n_1}{n_i}\right)$$

$$\text{Similarly, } E_{i2} = E_F - kT \ln\left(\frac{n_2}{n_i}\right)$$

$$\text{Therefore } E_{i1} - E_{i2} = kT \left[\ln\left(\frac{n_2}{n_i}\right) - \ln\left(\frac{n_1}{n_i}\right) \right] = kT \ln\left(\frac{n_2}{n_1}\right)$$

$$V_2 - V_1 = \frac{1}{q}(E_{i1} - E_{i2}) = \frac{kT}{q} \ln\left(\frac{n_2}{n_1}\right)$$

Quasi-Neutrality Approximation

- If the dopant concentration profile varies gradually with position, then the majority-carrier concentration distribution does not differ much from the dopant concentration distribution.

Summary

- **Carrier mobility varies with temperature**
 - decreases w/ increasing T if lattice scattering dominant
 - decreases w/ decreasing T if impurity scattering dominant

- **Electron/hole concentration gradient \rightarrow diffusion**

$$J_{N,\text{diff}} = qD_N \frac{dn}{dx} \quad J_{P,\text{diff}} = -qD_P \frac{dp}{dx}$$

- **Current flowing in a semiconductor is comprised of drift & diffusion components for electrons & holes**

$$J = J_{N,\text{drift}} + J_{N,\text{diff}} + J_{P,\text{drift}} + J_{P,\text{diff}}$$

- In equilibrium, $J_N = J_{N,\text{drift}} + J_{N,\text{diff}} = 0$

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- **The characteristic constants of drift and diffusion are related:**

$$\frac{D}{\mu} = \frac{kT}{q}$$

- **In thermal equilibrium, E_F is constant**
- **E_c represents the electron potential energy**
Variation in $E_c(x) \rightarrow$ variation in electric potential V

$$\text{Electric field } \mathcal{E} = \frac{dE_c}{dx} = \frac{dE_v}{dx}$$

- **$E - E_c =$ electron kinetic energy**

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